TRANSMITTAL LETTER (General - Patent Issued)

Docket No. BUR920000059US1

ECONTRA	(Sden Bryant	et	al.
~'' @ 11	10-		

U.S. Patent No.

6,960,806 B2

Issue Date

November 1, 2005

Title: DOUBLE GATED TRANSISTOR AND METHOD OF FABRICATION

COMMISSIONER FOR PATENTS:

Transmitted h	herewith is:
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Certificate of Correction

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Dated: 11 - 21 -2005

Jack P. Friedman, Ph.D. Reg. No. 44,688 Schmeiser, Olsen & Watts 3 Lear Jet Lane, Suite 201 Latham, NY 12110 (518)220-1850

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I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to "Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450" [37 CFR 1.8(a)] on

11-21-2005

(Date)

Betty Zuelsde Signature of Person Mailing Correspondence

Betty Zuelsdorf

Typed or Printed Name of Person Mailing Correspondence

UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO.: 6,960,806 B2

DATED : November 1, 2005

INVENTOR(S): Bryant et al.

It is certified that an error appears or errors appear in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Page 1, in the Title

Delete "DOUBLE GATED VERTICAL TRANSISTOR WITH DIFFERENT FIRST AND SECOND GATE MATERIALS" and insert -- DOUBLE GATED TRANSISTOR AND METHOD OF FABRICATION--

Column 1

Lines 1-3, delete "DOUBLE GATED VERTICAL TRANSISTOR WITH DIFFERENT FIRST AND SECOND GATE MATERIALS" and insert --DOUBLE GATED TRANSISTOR AND METHOD OF FABRICATION--

Column 11

Line 53, delete "n-type" and insert --p-type--Line 58, delete "tho" and insert --the--

Column 12

Line 9, delete "or claim 8" and insert --of claim 8--Line 34, delete "a first safe" and insert --a first gate--

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PATENT NO. 6,960,806 B2

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